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Victory RCx Pro Competitive Analysis Technology-Driven Parasitic Extraction Tool

Victory RCx Pro Competitors

- Raphael (Synopsys)
- QuickCap (Magma)
- Q3D (Ansoft)
- Cell-AN (OEA International Inc)



Victory RCx Pro Competitors (con't)

- Victory RCx Pro Advantages over competitors:
 - Best accuracy with user selected tolerance and adaptive local mesh refinement
 - Built-in realistic 3D etch and deposit process
 - Built-in physics based lithography simulator
 - Built-in netlist extractor
 - Automated contact and gate electrode SPICE netlist annotator
 - User selectable materials and boundary conditions
 - Best for Deep submicron CMOS, Flat Panel LCD and TFT, Memory Manufacturing and MEMS simulation

Applications

- Victory RCx Pro fits well as an RC extraction tool in the following markets
 - Deep submicron CMOS
 - Realistic 3D back end process simulations and accurate interconnect simulation with user-selected tolerance
 - Accurate via detailed capacitance and process analysis of individual problematic features, such as 45 nm via structures (via capacitance is now a significant source of capacitive delay)
- Victory RCx Pro fits well as an RC extraction tool in the following markets
 - Flat Panel LCD and TFT circuits
 - Special features to deal with high aspect ratio structure
 - SED Television technology
 - Memory manufacturing
 - SRAM and Flash Memory cell
 - MEMS simulation
 - Systems-on-a-chip brings together silicon-based microelectronics with micromachining technology

Advantages Against Competing Tools

- No restriction on geometry size 65nm, 45nm and below
- Realistic Structure Generation suitable for all technologies and arbitrary 3D shapes
- RC extractor capable of reproducing the lithographic effects of Optical Proximity Correction (OPC) sub wavelength effects, phase-shifts mask (PSM), misalignment, defocus, and CD
- True 3D, mask driven process simulation
- Realistic deposition, etch and lithography
- Netlist extractor to extract active device SPICE netlist
- Automatic back annotation of field solved resistances and capacitances onto extracted active device netlist for immediate SPICE analysis
- Optimize circuit performance as a function of back end process parameters and layout parameters

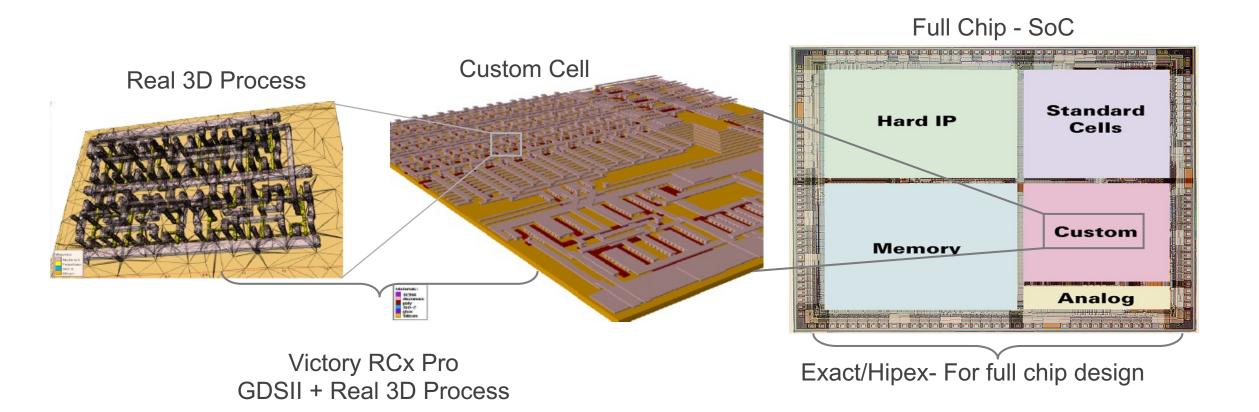


Advantages Against Competing Tools (cont)

- Full 3D field solver engine directly calculates parasitic RC extraction for best accuracy and handle dummies
- Automatic grid generation and refinement during 3D field solver calculation of capacitance and resistance
- Versatile small cells using fully realistic 3D processing or larger cells using geometric processing
- User-defined tolerance control on extraction accuracy
- 2D/3D structure Viewer (TonyPlot2D/3D)
- Symmetric boundary condition to allow users to perform Cyclic Simulations
- Selective area parasitic extraction enables maximum accuracy for critical layout windows



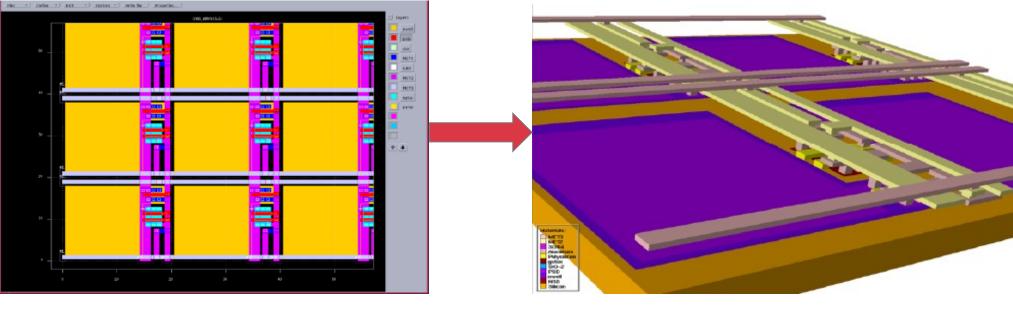
Victory RCx Pro – Simulator



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Victory RCx Pro – Layout Driven

• 3D Structures created from Mask Driven Intuitive Process Commands

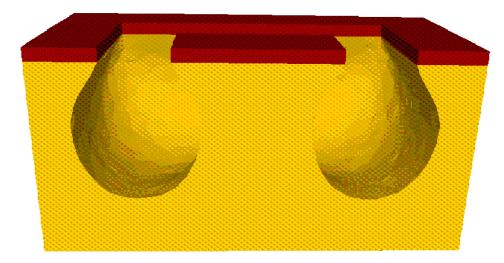


GDS2 Mask Layout

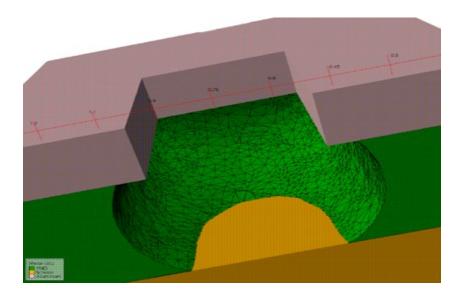
3D Structure



Victory RCx Pro – Tracking Fronts in Etch/Deposition



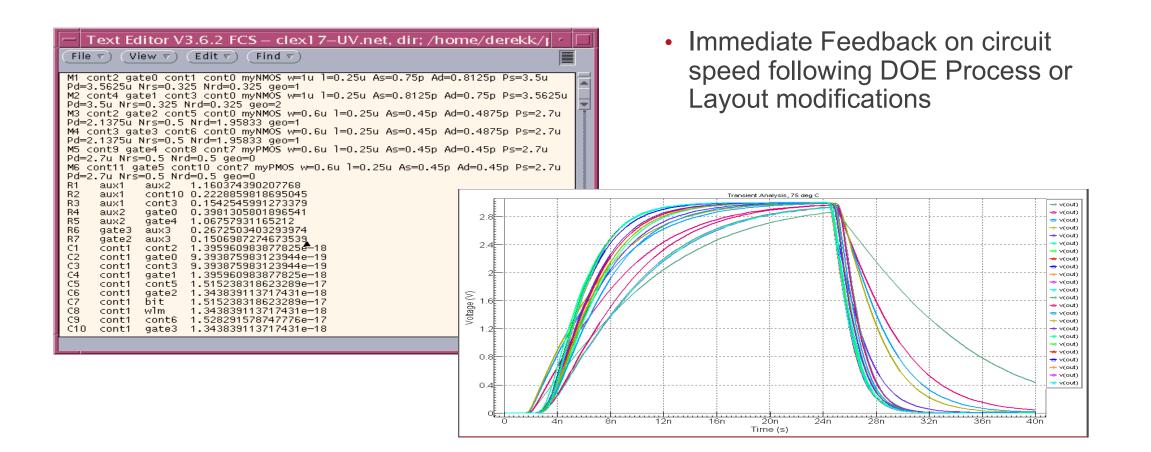
Directional etching; r_{dir} is determined by the visible "cone" from above.



Complex etching capability.

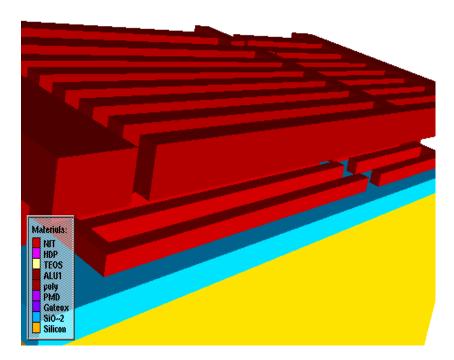


Automated Annotated Spice Netlist Generation

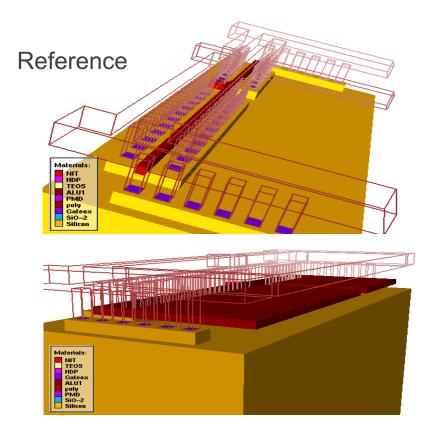


Victory RCx Pro – Deep Submicron CMOS Example

• Three different ring oscillators



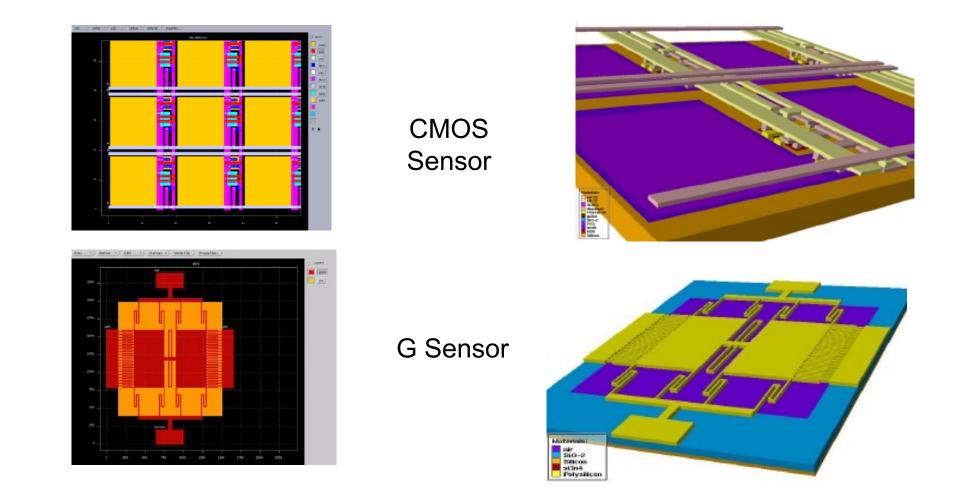
"Fringes" Metal1 over Poly



Metal1 plate overlapping Poly plate

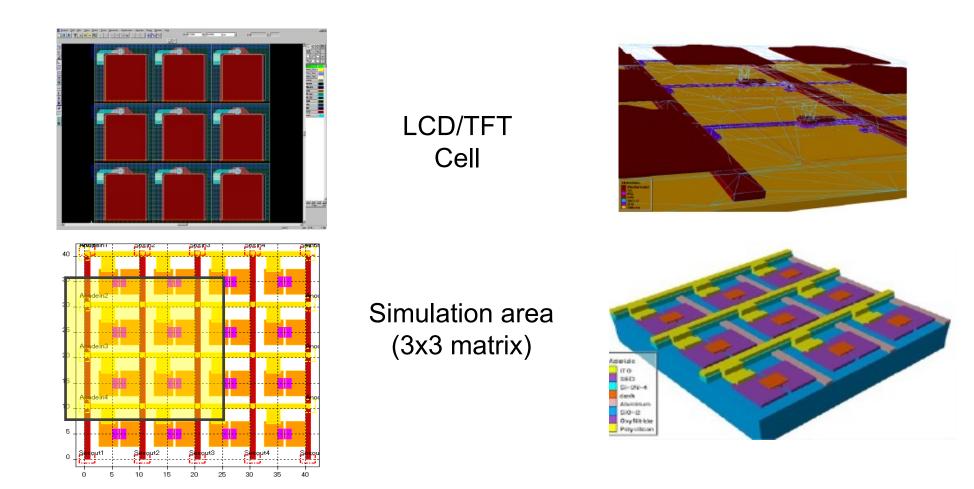


Victory RCx Pro – Deep Submicron CMOS Example



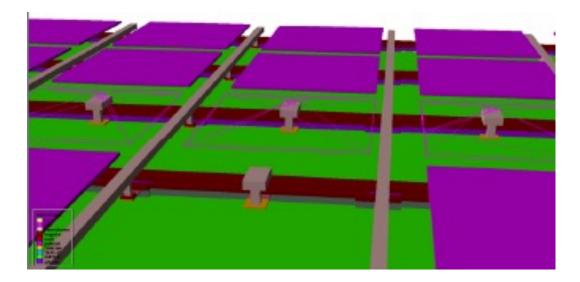


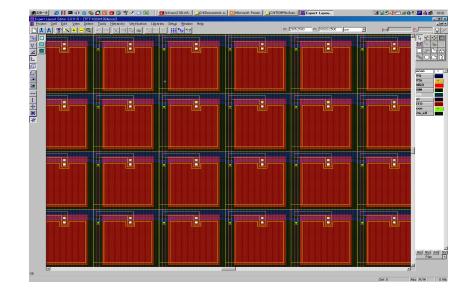
Victory RCx PRo – Flat Panel LCD and TFT Example





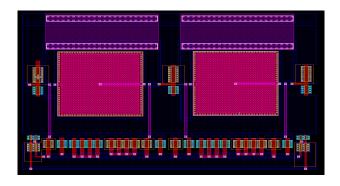
Victory RCx Pro – Flat Panel LCD, TFT Example



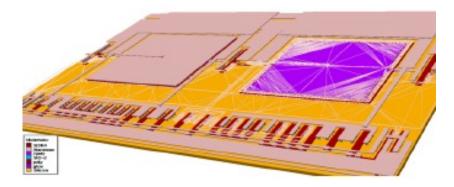


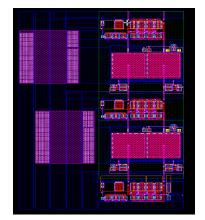


Victory RCx Pro – Comparator Circuit Examples

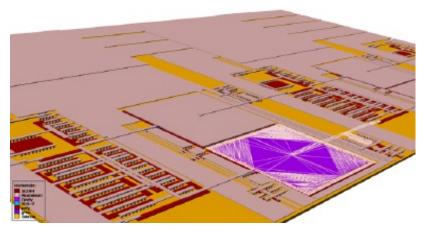


Comparator 1



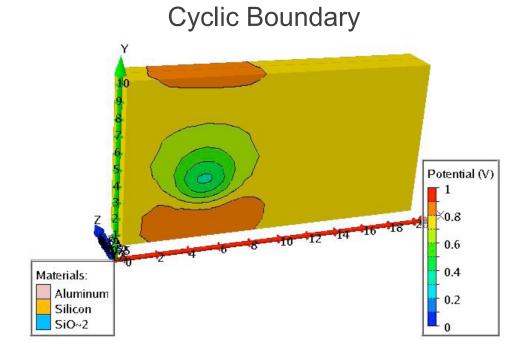


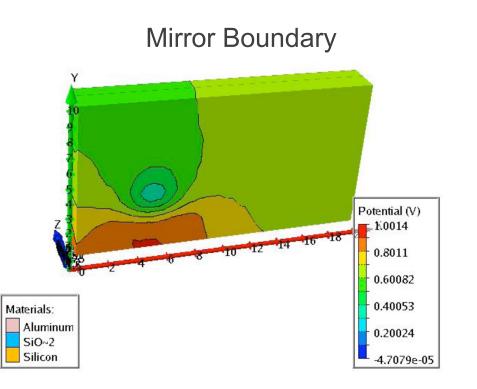
Comparator 2





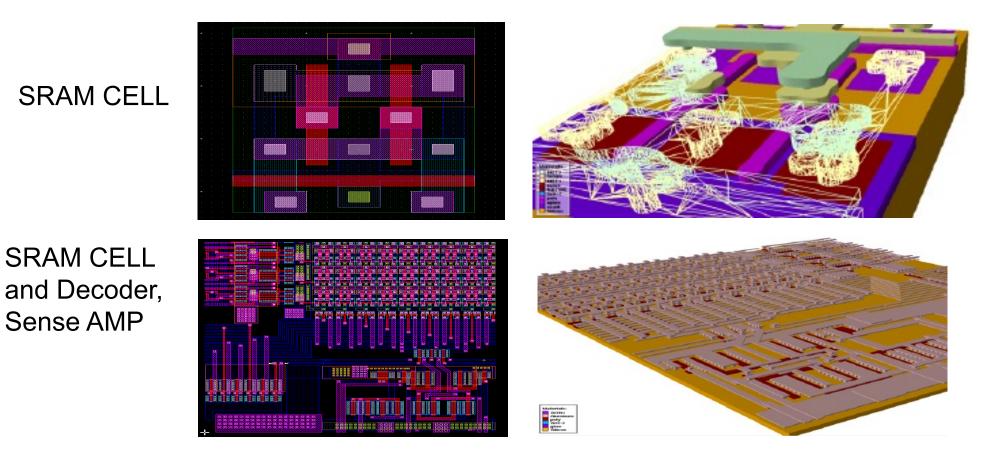
Victory RCx Pro – Unique Functionality





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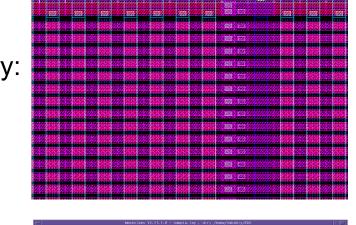
Victory RCx Pro – SRAM Example



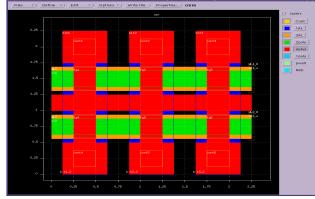


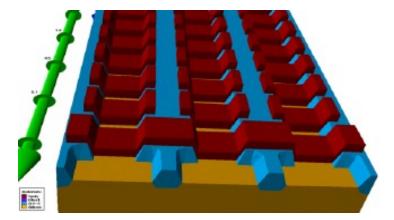
Victory RCx Pro – Flash Memory Example

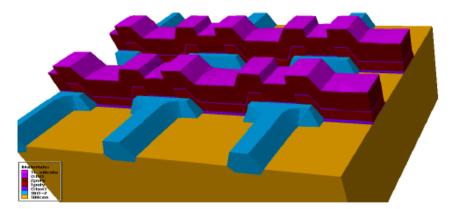
Flash Memory: NAND



Flash Memory: NOR

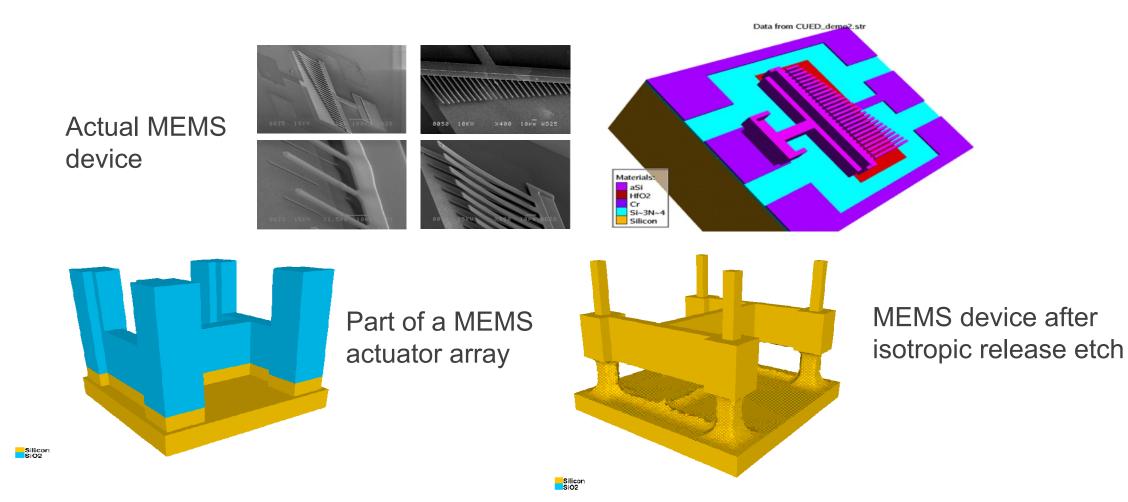








Victory RCx Pro – MEMS Example





Victory RCx Pro – Conclusions

- Victory RCx Pro is your solution for parasitic RC extraction where MAXIMUM ACCURACY is required
- Highly versatile tool ideal solution for:
- Deep sub-micron CMOS and SOI parasitic extraction for all technology nodes
- TFT pixel arrays where many conformal depositions make capacitance analysis using traditional rule based tools too inaccurate due to multiple topology effects.
- True 3D parasitic interconnect effects are automatically passed to SmartSpice to enable the most accurate circuit simulations